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Form PTO-1449 (Rev. 2-32)

U.S. Department of Commerce Patent & Trademark Office

Atty. Docket No.

Q64222

Serial No.: Division of

U.S. Appn. 09/374,112

Confirmation No.: Not Assigned

INFORMATION DISCLOSURE STATEMENT
(Use several sheets if necessary)

Applicant: TAMURA, TAKAHIRO

Filing Date: June 6, 2001

Group: Not Assigned

			June 6, 2001	Not Ass	ignou	
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